



SHEET 1 OF 1

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (Substitute for form 1449/PTO)				ATTY. DOCKET NO. <b>043888-0456</b>		SERIAL NO. <b>10/572,590</b>	
				APPLICANT <b>Takashi TAKEUCHI, et al.</b>			
				FILING DATE <b>March 20, 2006</b>		GROUP <b>1795</b>	
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code <sup>2</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
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<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes-Number 4-Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines Where Relevant Figures Appear	Translation Yes      No
<b>OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
		<b>Chinese Office Action, with English translation, issued in Chinese Patent Application No. CN 2004800320470, mailed September 12, 2008.</b>					
		<b>LEVASSEUR, S., et al., "On the Li<sub>x</sub>Co<sub>1-y</sub>Mg<sub>y</sub>O<sub>2</sub> system upon deintercalation: electrochemical, electronic properties and <sup>7</sup>Li MAS NMR studies", Journal of Power Sources, 2002, Pages 419-427, Vol. 112, Elsevier Science B.V.</b>					
EXAMINER				DATE CONSIDERED			

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.